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# Implicit Solvent Methods and DFT+U

CP2K User Tutorial: "Computational Spectroscopy", Uni Paderborn, 28 August 2018

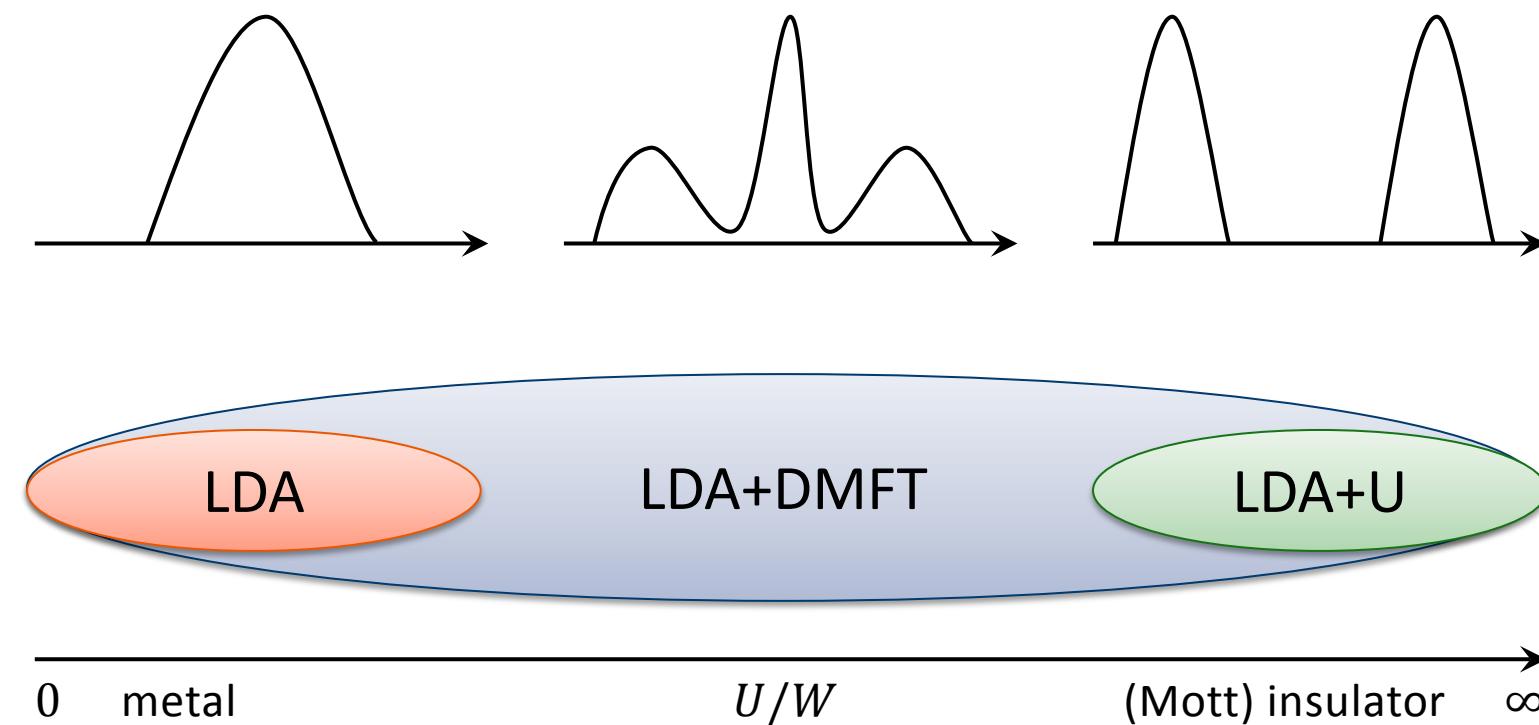
# DFT+U

# Local density approximation (LDA)

- Plain DFT (LDA, GGA) performs unexpectedly well for many solid state systems
- But:
  - LDA provides a poor description of the Coulomb interaction
  - The LDA functional is derived from a weakly correlated reference system, the jellium model (uniform or homogeneous electron gas)
  - Generalised Gradient Approximation (GGA) does not overcome these shortcomings as it is still a “local” approximation by adding only gradient information
  - Fortuitous error cancellation obscures the deficiencies
  - LDA fails badly for *strongly correlated systems* like **transition metal (TM) oxides** and **heavy fermion materials** with partially filled 4f and 5f orbitals

# Mott insulator

- Hubbard bands form as an effect of the electronic correlation:
  - LDA bands split into two sets of bands separated by a local Coulomb repulsion  $U$  and band width  $W \rightarrow$  Mott insulator



# Strongly correlated systems

- Though it is possible to calculate the Hubbard parameter  $U$  using linear response theory\*, it is usually treated as an empirical fitting parameter
- Fixed  $U$  parameter does not adapt to the chemical environment (e.g. change of oxidation state)
- Occurrence of meta-stable states for heavy fermion materials like  $\text{CeO}_2$ ,  $\text{UO}_2$  etc.  
⇒ major obstacle technically
- On-going development, e.g. dynamical mean field theory (LDA+DMFT)
  - However, such methods are computationally very expensive
  - Accessible model system sizes are quite limited currently ( $\approx 30$  atoms per cell)
  - Analytical energy gradients, i.e. atomic forces, are not straightforwardly available

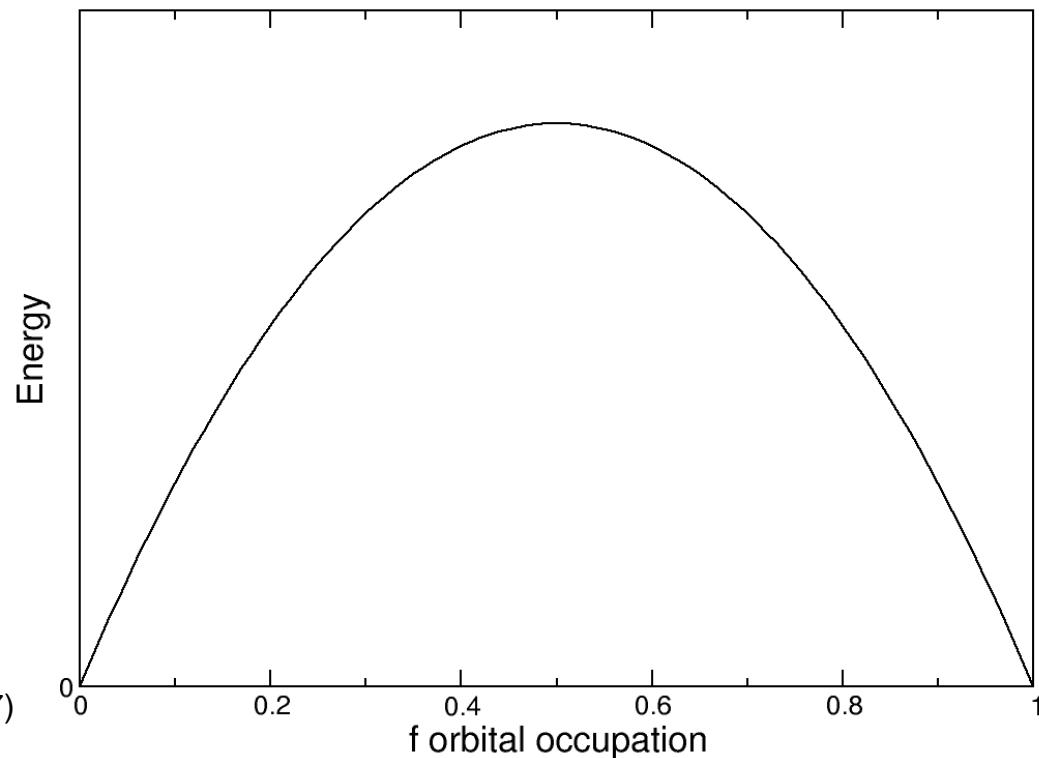
\*Cococcioni and Gironcoli, Phys. Rev. B **71**, 035105

# DFT+U method

- Hubbard correction term is added to the DFT energy functional as an atomic on-site term (V. I. Anisimov et al., Phys. Rev. B **44**, 943 (1991))
- Explicit correction that acts as an energy penalty function, e.g. Dudarev\*:

$$E_U = \frac{U_{\text{eff}}}{2} \sum_{\sigma, I} \text{Tr}[\mathbf{n}^{\sigma, I} (\mathbf{1} - \mathbf{n}^{\sigma, I})] \text{ with atom } I \text{ and spin } \sigma$$

- Computationally cheap
- Right physical effect
- Rotationally invariant
- Effective  $U$  parameter:
- $U_{\text{eff}} = U - J$



\*Dudarev et al., Phil. Mag. B **75**, 613 (1997)

# Population analyses

- Orbital based methods:

– Chirgwin and Coulson:  $\mathbf{P} = \frac{1}{2}(\mathbf{D}\mathbf{S} + \mathbf{S}\mathbf{D})$

– Mulliken:  $\mathbf{P} = \mathbf{D} \mathbf{S}$

– Löwdin:  $\mathbf{P} = \mathbf{S}^{1/2} \mathbf{D} \mathbf{S}^{1/2}$

with density matrix  $\mathbf{D}$ , overlap matrix  $\mathbf{S}$ , and occupation matrix  $\mathbf{P}$

- Partitioning of the electronic density:

– Bader charges: Gradient of the electronic charge density (zero-flux surface)  
– Hirshfeld charges: Difference to unrelaxed atomic densities (pro-density)

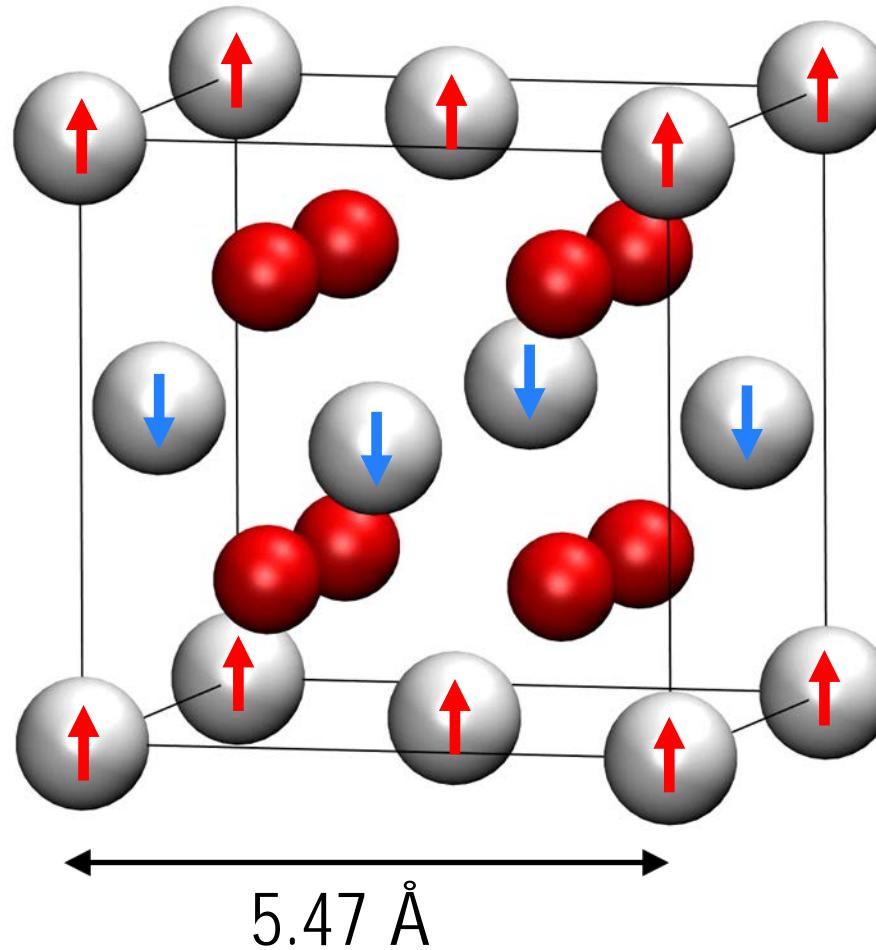
- Potential derived charges methods

- Moment derived charges

# Tackling the meta-stable state problem

- Occupation matrix control (OMC)  
B. Dorado et al., Phys. Rev. B **79**, 235125 (2009)
- U ramping method  
B. Meredig et al., Phys. Rev. B **82**, 195128 (2010)
- Quasi-annealing (QA) method  
H. Y. Geng et al., Phys. Rev. B **82**, 094106 (2010)
- Controlled symmetry reduction (CSR) method  
D. Gryaznov et al., Phys. Chem. Chem. Phys. **14**, 4482 (2012)
- f occupation smearing and U ramping (FOUR)  
J. Rabone and M. Krack, Comput. Mat. Sci. **71**, 157 (2013)
- Local electronic minima inhibition by averaging occupations (LEMIAO)  
J. Rabone and M. Krack, Comput. Mat. Sci. **71**, 157 (2013)

# Example: Uranium dioxide ( $\text{UO}_2$ )



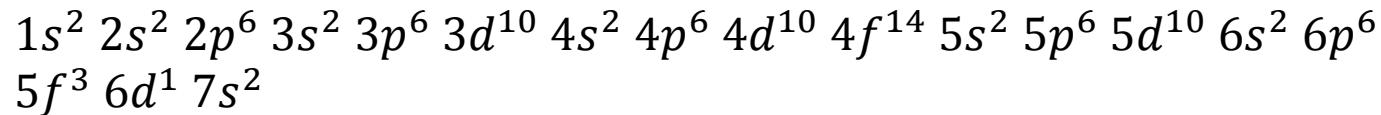
# Force evaluation section

- Antiferromagnetic ground state below 30.4 K:

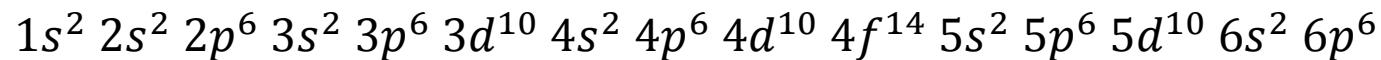
```
&FORCE_EVAL
  METHOD Quickstep
  STRESS_TENSOR analytical
  &DFT
    CHARGE 0
    LSD
    MULTIPLICITY 1
    PLUS_U_METHOD Mulliken
    .
    .
    .
  &END DFT
  .
  .
  .
&END FORCE_EVAL
```

# Example: Uranium dioxide ( $\text{UO}_2$ )

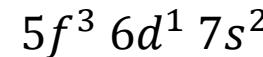
- All-electron configuration of uranium: 92 electrons



- 86 core electrons:

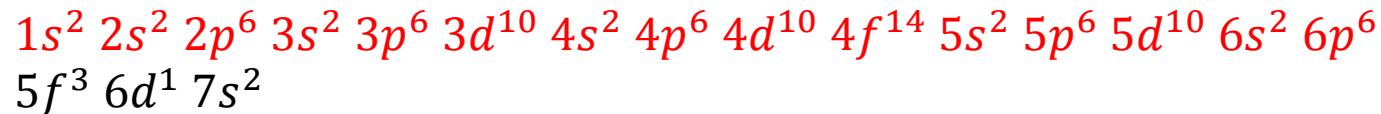


- 6 valence electrons:



# Example: Uranium dioxide ( $\text{UO}_2$ )

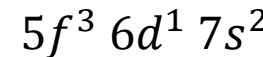
- All-electron configuration of uranium: 92 electrons



- 86 core electrons:



- 6 valence electrons:



# Example: Uranium dioxide ( $\text{UO}_2$ )

- All-electron configuration of uranium: 92 electrons

$1s^2 2s^2 2p^6 3s^2 3p^6 3d^{10} 4s^2 4p^6 4d^{10} 4f^{14} 5s^2 5p^6 5d^{10} 6s^2 6p^6$   
 $5f^3 6d^1 7s^2$

- 86 core electrons:

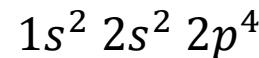
$1s^2 2s^2 2p^6 3s^2 3p^6 3d^{10} 4s^2 4p^6 4d^{10} 4f^{14} 5s^2 5p^6 5d^{10} 6s^2 6p^6$

- 6 valence electrons:

$5f^3 6d^1 7s^2$

# Example: Uranium dioxide ( $\text{UO}_2$ )

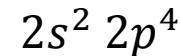
- All-electron configuration of oxygen: 8 electrons



- 2 core electrons:

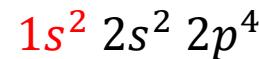


- 6 valence electrons:



# Example: Uranium dioxide ( $\text{UO}_2$ )

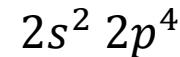
- All-electron configuration of oxygen: 8 electrons



- 2 core electrons:



- 6 valence electrons:



# Example: Uranium dioxide ( $\text{UO}_2$ )

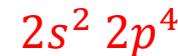
- All-electron configuration of oxygen: 8 electrons



- 2 core electrons:



- 6 valence electrons:

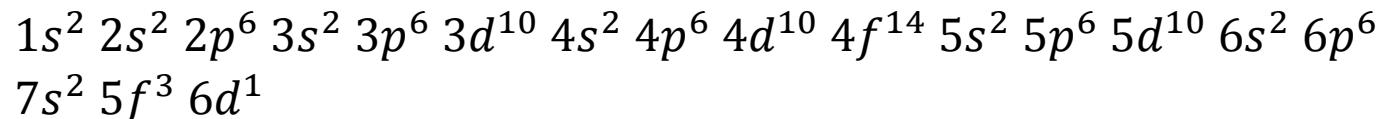


# Example: Uranium dioxide ( $\text{UO}_2$ )

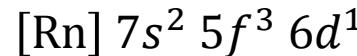
- All-electron configuration of oxygen: 8 electrons  
 $1s^2 2s^2 2p^4$
- Pseudo atom configuration of oxygen: 2 + 6 electrons  
 $[\text{He}] 2s^2 2p^4$

# Example: Uranium dioxide ( $\text{UO}_2$ )

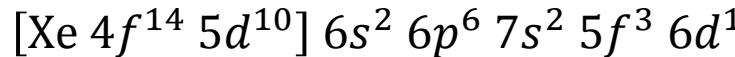
- All-electron configuration of uranium: 92 electrons



- Large-core pseudo atom configuration of uranium: 86 + 6 electrons



- Medium-core pseudo atom configuration of uranium: 78 + 14 electrons



- Small-core pseudo atom configuration of uranium: 60 + 32 electrons



# DFT+U section in the atomic kind section

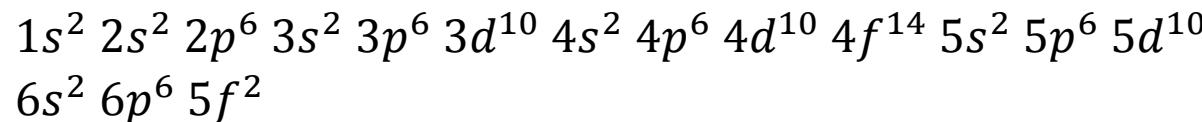
```
&KIND O
  BASIS_SET DZVP-MOLOPT-SR-GTH-q6
  POTENTIAL GTH-PBE-q6
  &BS
    ...
  &END BS
  ! Not needed for O
&END KIND
```

# DFT+U section in the atomic kind section

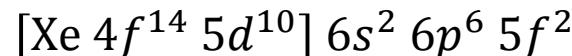
```
&KIND Ua
  BASIS_SET DZVP-MOLOPT-GTH-q14
  ELEMENT U
  POTENTIAL GTH-PBE-q14
  &BS
    . . .
  &END BS
  &DFT_PLUS_U on
    L 3
    U_MINUS_J [eV] 2.00
    &ENFORCE_OCCUPATION on/off
    . . .
  &END ENFORCE_OCCUPATION
  &END DFT_PLUS_U
&END KIND
```

# Example: Uranium dioxide ( $\text{UO}_2$ )

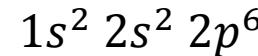
- Electronic configuration of  $\text{U}^{4+}$ :



- Medium-core pseudo atom configuration of  $\text{U}^{4+}$ :



- Electronic configuration of  $\text{O}^{2-}$ :

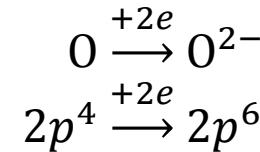


- Pseudo atom configuration of  $\text{O}^{2-}$ :



# BS section: Initial atomic orbital occupations

- Set up the (on-site) atomic orbital occupations for O<sup>2-</sup>:

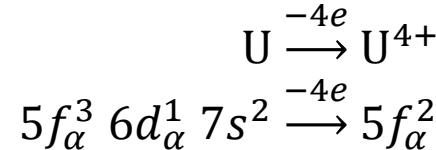


- BS section input is not processed quite intuitively:

```
&BS
  &ALPHA
    N   2 ! 2
    L   1 ! p
    NEL +2 ! (4 + 2)/2 = 3 alpha 2p electrons
  &END ALPHA
  &BETA
    N   2 ! 2
    L   1 ! p
    NEL +2 ! (4 + 2)/2 = 3 beta 2p electrons
  &END BETA
&END BS
```

# BS section: Initial atomic orbital occupations

- Set up the (on-site) atomic orbital occupations for U<sup>4+</sup>:



- On-site triplet state for U<sup>4+</sup> for the spin-up (alpha) uranium atoms **Ua** and swap **&ALPHA** and **&BETA** sections for the spin-down (beta) **Ub** kind (not shown):

```
&BS
```

```
&ALPHA
```

```
N      5      6      7
L      3      2      0
```

```
NEL    +1    -1    -2 ! (3 + 1)/2 = 2 alpha 5f electrons
```

```
&END ALPHA
```

```
&BETA
```

```
N      5      6      7
L      3      2      0
```

```
NEL    -3    -1    -2 ! remove all beta valence electrons
```

```
&END BETA
```

```
&END BS
```

# Example: Uranium dioxide ( $\text{UO}_2$ )

- Two alpha electrons in seven 5f orbitals:  $\binom{7}{2} = 21$  combinations

	$f_{-3}$	$f_{-2}$	$f_{-1}$	$f_0$	$f_{+1}$	$f_{+2}$	$f_{+3}$
1	↑	↑					
2	↑		↑				
3	↑			↑			
4	↑				↑		
5	↑					↑	
6							↑
7		↑	↑				
8		↑		↑			
9		↑			↑		
10		↑				↑	

	$f_{-3}$	$f_{-2}$	$f_{-1}$	$f_0$	$f_{+1}$	$f_{+2}$	$f_{+3}$
11			↑				↑
12				↑	↑		
13					↑		↑
14					↑		↑
15						↑	↑
16						↑	↑
17						↑	↑
18						↑	
19						↑	↑
20						↑	
21							↑

# Print DFT+U specific information

- Print occupation of each atom with a  $U$  value greater zero:

```
&GLOBAL
  PRINT_LEVEL medium
  .
  .
  .
&END GLOBAL
```

```
&FORCE_EVAL
  .
  .
  .
&DFT
```

```
  .
  .
  .
  &PRINT
    &PLUS_U on
      &EACH
        QS_SCF 1
      &END EACH
    &END PLUS_U
  &END PRINT
```

```
  .
  .
  .
&END DFT
```

```
  .
  .
  .
&END FORCE_EVAL
```

# Print DFT+U specific information

- Use a tiny  $U$  value to trigger printout for the  $U = 0$  case:

```
&DFT_PLUS_U
  .
  .
  .
  U_MINUS_J [eV] 2.00E-20
  .
  .
  .
&END DFT_PLUS_U
```

# Occupation control

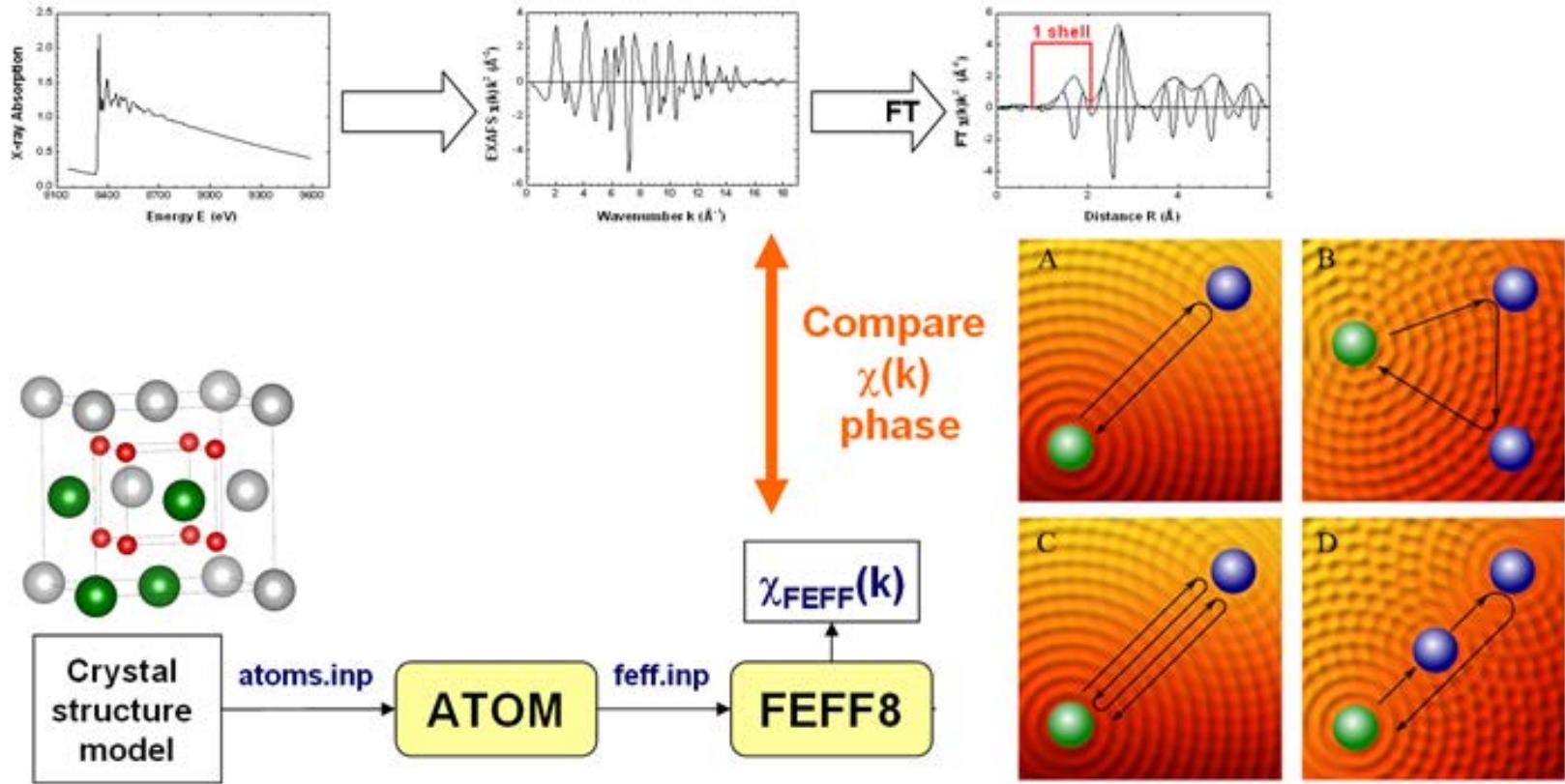
- A specific (initial) orbital occupation can be enforced:

```
&DFT_PLUS_U
  .
  .
&ENFORCE_OCCUPATION on/off
  EPS_SCF 1.0E-5 ! Enforce until a certain SCF convergence is reached
  MAX_SCF 20      ! Enforce occupation for first 20 SCF iterations
  ORBITALS -3 -2 -1 +0 +1 +2 +3 ! Smear f electrons over all f orbitals
  SMEAR on
  &END ENFORCE_OCCUPATION
  .
  .
&END DFT_PLUS_U
```

- Alternatively, define and enforce a specific orbital occupation pattern, e.g.

```
ORBITALS -3 -1
```

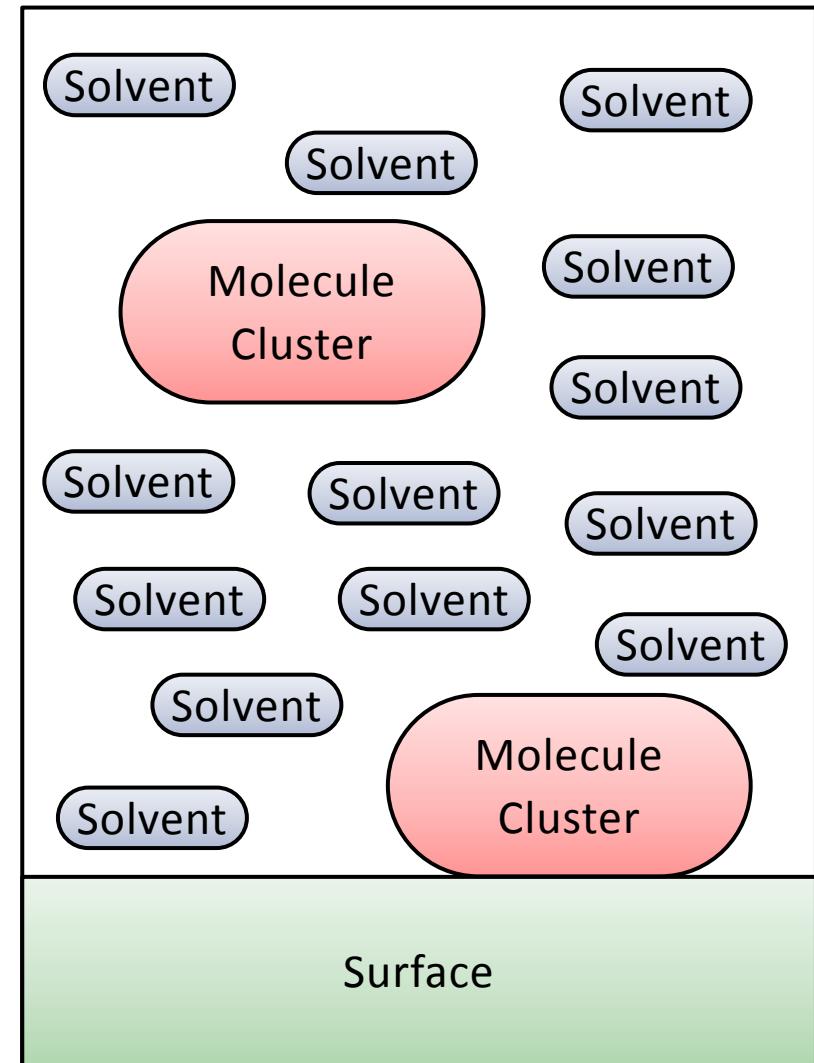
# Example: XAFS spectra simulation



# Implicit Solvent Methods

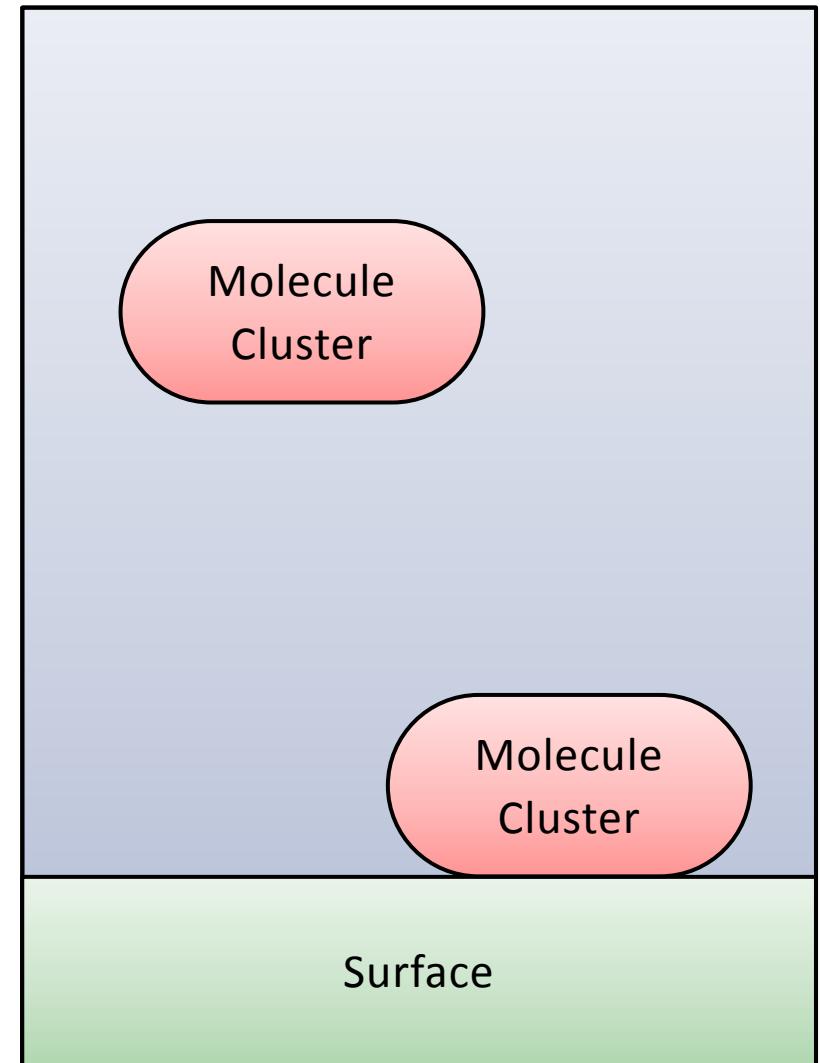
# Modelling of solvation effects

- Vacuum
- Gas phase
- Explicit solvent with solute



# Modelling of solvation effects

- Vacuum
- Gas phase
- Explicit solvent with solute
- Implicit solvent with solute

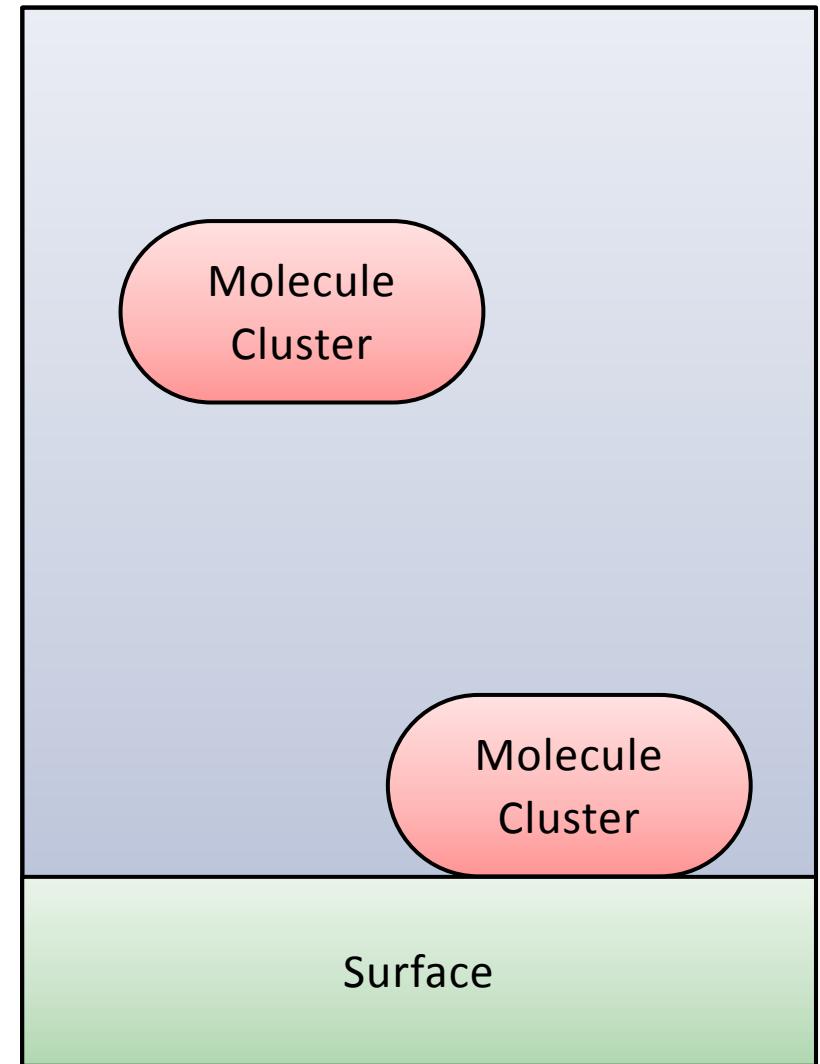


# Continuum solvation models

- Polarisable continuum model (PCM, Tomasi et al.)
- Conductor-like screening model (COSMO, Klamt et al.)
- Smooth dielectric models are needed for molecular dynamics (MD) simulations

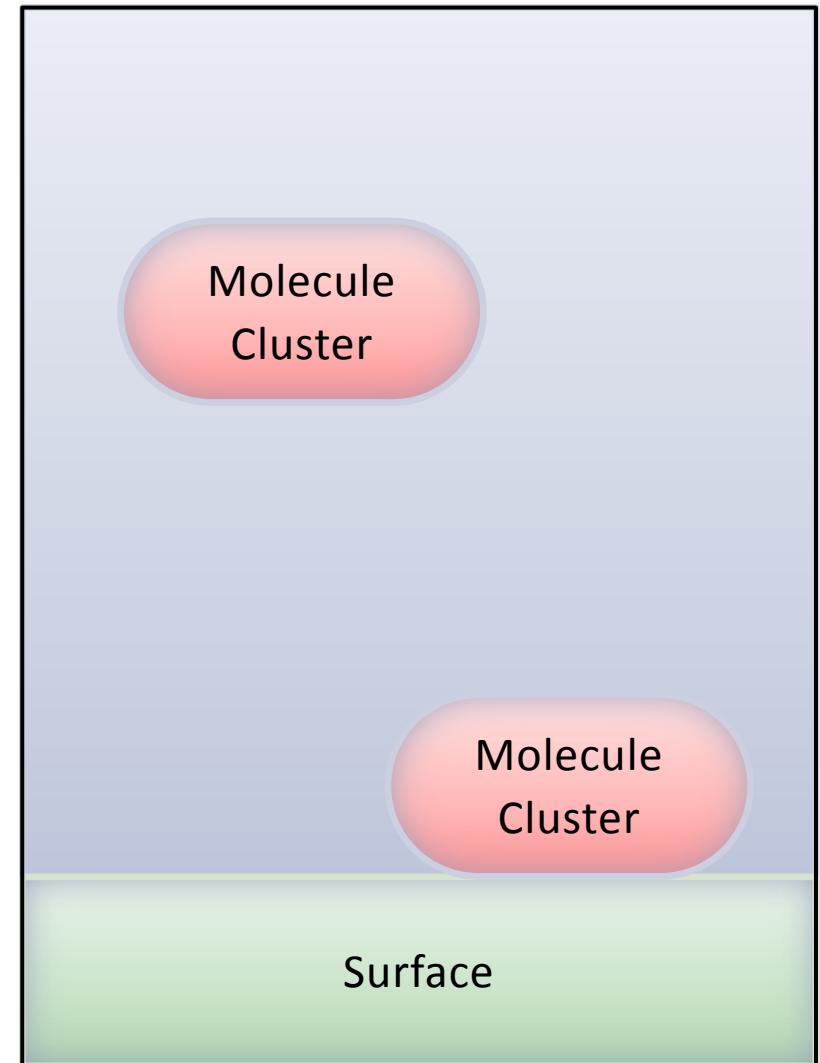
# Modelling of solvation effects

- Vacuum
- Gas phase
- Explicit solvent with solute
- Implicit solvent with solute



# Modelling of solvation effects

- Vacuum
- Gas phase
- Explicit solvent with solute
- Implicit solvent with solute
- Smoothed solute-solvent transition



# Pros and Cons of an implicit solvent approach

- Explicit solute-solvent interactions are missing
  - Pros:
    - Shortcomings of standard DFT in the description of van der Waals and hydrogen bonds w.r.t. the solvent do not matter
    - Shorter sampling times needed to obtain meaningful thermodynamic averages
  - Cons:
    - No detailed description of hydrogen bonds (network)
    - Potential (chemical) reactions between solvent and solute are excluded a priori
- No explicit solvent atoms
  - Pros:
    - Significant reduction in problem size especially for localised basis set methods
    - More efficient sampling
  - Cons:
    - Additional (nested) convergence cycle for polarisation charge required
    - No information about solvation shells (detailed feedback of the solvent)
    - Potentially more noisy forces due to finite differences approach

# Smoothed dielectric function

- Dielectric as a smoothed self-consistent function of the electronic density:

$$\epsilon(\mathbf{r}) \equiv \epsilon[\rho^{\text{elec}}(\mathbf{r})] = \begin{cases} 1 & \text{large } \rho^{\text{elec}} \\ \epsilon_0 & \rho^{\text{elec}} \rightarrow 0 \end{cases}$$

- J.-L. Fattebert and F. Gygi, J. Comput. Chem. **23**, 662 (2002)
- J.-L. Fattebert and F. Gygi, Int. J. Quantum Chem. **93**, 139 (2003)
- O. Andreussi et al., J. Chem. Phys. **136**, 064102 (2012)

# Self-consistent Continuum Solvation (SCCS)

- Adding a dielectric medium to the system

$$\epsilon(\mathbf{r}) \equiv \epsilon[\rho^{\text{elec}}(\mathbf{r})]$$

$$\nabla^2 \phi^{\text{tot}}(\mathbf{r}) = -4\pi \rho^{\text{solute}}(\mathbf{r}) \quad \text{with } \rho^{\text{solute}}(\mathbf{r}) = \rho^{\text{ions}}(\mathbf{r}) + \rho^{\text{elec}}(\mathbf{r})$$

$$\nabla \cdot \epsilon[\rho^{\text{elec}}(\mathbf{r})] \phi^{\text{tot}}(\mathbf{r}) = -4\pi \rho^{\text{solute}}(\mathbf{r})$$

$$\nabla \cdot \mathbf{E}(\mathbf{r}) = 4\pi \rho^{\text{solute}}(\mathbf{r}) - 4\pi \cdot \mathbf{P}(\mathbf{r})$$

$$\rho^{\text{pol}}(\mathbf{r}) = -\nabla \cdot \mathbf{P}(\mathbf{r}) = \nabla \cdot \left( \frac{\epsilon(\rho^{\text{elec}}(\mathbf{r})) - 1}{4\pi} \nabla \phi^{\text{tot}}(\mathbf{r}) \right)$$

- Finally a vacuum-like Poisson problem is recovered

$$\nabla^2 \phi^{\text{tot}}(\mathbf{r}) = -4\pi (\rho^{\text{solute}}(\mathbf{r}) + \rho^{\text{pol}}(\mathbf{r}))$$

# Self-consistent Continuum Solvation (SCCS)

- Vacuum-like Poisson problem is recovered

$$\nabla^2 \phi^{\text{tot}}(\mathbf{r}) = -4\pi(\rho^{\text{solute}}(\mathbf{r}) + \rho^{\text{pol}}(\mathbf{r}))$$

- Energy term

$$E^{\text{el}} = E^{\text{solute}} + E^{\text{pol}}$$

# Solvation free energy

- Solvation free energy

$$\Delta G^{\text{sol}} = \Delta G^{\text{el}} + G^{\text{rep}} + G^{\text{dis}} + G^{\text{cav}} + \Delta G^{\text{tm}} + P\Delta V$$

- Electrostatic contribution:

$$\Delta G^{\text{el}} = G^{\text{el}} - G^0$$

with the energy  $G^0$  of the solute in vacuum

- Repulsion term\*:

$$G^{\text{rep}} = \alpha S$$

where  $S$  is the (quantum) surface of the cavity

- Dispersion term\*:

$$G^{\text{dis}} = \beta V$$

where  $V$  is the (quantum) volume of the cavity

\*Scherlis et al., J. Chem. Phys. 124, 074103 (2006)

# Solvation free energy

- Cavitation term\*:

$$G^{\text{cav}} = \gamma S$$

where  $S$  is the (quantum) surface of the cavity

- Thermal motion term  $G^{\text{tm}}$  and the volume change term  $P\Delta V$  are often ignored
- Collecting all terms results in an approximation for the solvation free energy

$$\Delta G^{\text{sol}} \approx \Delta G^{\text{el}}(\epsilon_0, \rho_{\min}, \rho_{\max}) + (\alpha + \gamma) S + \beta V$$

- Quantum volume  $V$  and surface  $S$ :
  - M. Cococcioni et al., Phys. Rev. Lett. **94**, 145501 (2005)

\*Scherlis et al., J. Chem. Phys. 124, 074103 (2006)

# SCCS input section

```
&SCCS on/off
  ALPHA [N*m^-1] 0.0
  BETA [kbar] 0.0
  DELTA_RHO 2.0E-5
  DERIVATIVE_METHOD cd3/cd5/cd7/fft
  DIELECTRIC_CONSTANT 78.36
  EPS_SCCS 1.0E-6
  GAMMA [mN/m] 0.0
  @IF ${OT}
    EPS_SCF 0.03
  @ENDIF
  @IF ${TD}
    EPS_SCF 0.3
  @ENDIF
  MAX_ITER 100
  METHOD Andreussi/Fattebert-Gygi
  MIXING 0.6
  .
  .
  .
&END SCCS
```

# Dielectric functions

- Fattebert-Gygi

$$\epsilon[\rho^{\text{elec}}(\mathbf{r})] = 1 + \frac{\epsilon_0 - 1}{2} \left( 1 + \frac{1 - (\rho^{\text{elec}}/\rho_0)^{2\beta}}{1 + (\rho^{\text{elec}}/\rho_0)^{2\beta}} \right)$$

- Andreussi et al.

$$\epsilon[\rho^{\text{elec}}(\mathbf{r})] = \begin{cases} 1 & \rho^{\text{elec}} > \rho_{\max} \\ \exp(t(\ln \rho^{\text{elec}})) & \rho_{\min} < \rho^{\text{elec}} < \rho_{\max} \\ \epsilon_0 & \rho^{\text{elec}} < \rho_{\min} \end{cases}$$

$$t(x) = \frac{\ln \epsilon_0}{2\pi} \left[ 2\pi \frac{\ln \rho_{\max} - x}{\ln \rho_{\max} - \ln \rho_{\min}} - \sin \left( 2\pi \frac{\ln \rho_{\max} - x}{\ln \rho_{\max} - \ln \rho_{\min}} \right) \right]$$

# Smoothing methods for the dielectric function

```
&SCCS on/off
. . .
DIELECTRIC_CONSTANT 78.36
METHOD Andreussi/Fattebert-Gygi
. . .
&ANDREUSSI
RHO_MAX 0.001
RHO_MIN 0.0001
&END ANDREUSSI
. . .
&FATTEBERT-GYGI
BETA 1.3
RHO_ZERO 0.0004
&END FATTEBERT-GYGI
. . .
&END SCCS
```

# Questions or comments?

